

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/601,958	08/10/2000	JYOTI KIRON BHARDWAJ	WLJ.056	5262	
JONES VOLENTINE,LLC 12200 SUNRISE VALLEY DRIVE SUITE 150 RESTON, VA 20191			EXAMINER		
			HASSANZADEH, PARVIZ		
			ART UNIT	PAPER NUMBER	
			1763	1=	
			DATE MAILED: 10/23/2002	' -	

Please find below and/or attached an Office communication concerning this application or proceeding.

				160			
		Application	No.	Applicant(s)			
Office Action Summary		09/601,958		BHARDWAJ ET AL.			
		Examiner		Art Unit			
	•	Parviz Hass		1763			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address							
THE M - Extens after S - If the p - If NO - Failure - Any re	PRIENED STATUTORY PERIOD FOR REF ALLING DATE OF THIS COMMUNICATION is ions of time may be available under the provisions of 37 CFR in (6) MONTHS from the mailing date of this communication. Deriod for reply specified above is less than thirty (30) days, a reperiod for reply is specified above, the maximum statutory period for reply within the set or extended period for reply will, by statistic ply received by the Office later than three months after the main dispatent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, reply within the statuto od will apply and will e	, however, may a reply be ry minimum of thirty (30) expire SIX (6) MONTHS fr thion to become ABANDO	e timely filed days will be considered timely. om the mailing date of this communication. NED (35 U.S.C. § 133).			
1)⊠	Responsive to communication(s) filed on 3	0 September 20	<u>002</u> .				
2a)□	This action is FINAL . 2b)⊠	This action is n	on-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. Disposition of Claims							
4)⊠	Claim(s) 1-24 and 26-49 is/are pending in t						
	4a) Of the above claim(s) <u>3,5,10,11,16-20,2</u>		is/are withdrawn	from consideration.			
	Claim(s) is/are allowed.						
	6)⊠ Claim(s) <u>1,2,4,6-9,12-15,21 and 26-28</u> is/are rejected.						
	Claim(s) <u>1, 27</u> is/are objected to.						
	Claim(s) are subject to restriction and	d/or election red	quirement.				
Applicati	on Papers						
	The specification is objected to by the Exam		_				
10)⊠ The drawing(s) filed on <u>10 August 2000</u> is/are: a)⊠ accepted or b)⊡ objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.							
If approved, corrected drawings are required in reply to this Office action.							
,	The oath or declaration is objected to by the	e Examiner.					
	under 35 U.S.C. §§ 119 and 120		05 H 0 0 5 44	10(a) (d) or (f)			
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).							
a)	⊠ All b) Some * c) None of:						
	1. Certified copies of the priority documents have been received.						
	2. Certified copies of the priority documents have been received in Application No.						
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.							
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).							
l	a) The translation of the foreign language Acknowledgment is made of a claim for don	provisional ap	plication has been	received.			
Attachmer							
2) Noti	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948 mation Disclosure Statement(s) (PTO-1449) Paper No	s) o(s) <u>4,6,7</u> .		nmary (PTO-413) Paper No(s) rmal Patent Application (PTO-152)			

Art Unit: 1763

DETAILED ACTION

Election/Restrictions

Applicant's election without traverse of Species 1, Group 1, claims 1, 2, 4, 6-9, 12-15, 21 and 26-28 in Paper No. 12 is acknowledged.

Claims 3, 5, 10, 11, 16-20, 22-24 and 29-49 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected Species and method, there being no allowable generic or linking claim. Election was made **without** traverse in Paper No. 12.

Specification

This application does not contain an abstract of the disclosure as required by 37 CFR 1.72(b). An abstract on a separate sheet is required.

The disclosure is objected to because of the following informalities:

it is suggested to change "utilise, optimisation, homogenising, energized, localise" to "utilize, optimization, homogenizing, energized, localize" through the entire of the specification; on page 22, line 11, it is suggested to delete "a" after "grid" and insert "a" before "grid"; on page 25, line 17, it is suggested to delete "may" after "alternatively"; on page 31, line 19, it is suggested to insert a blank space between "17A" and "consists". Appropriate correction is required.

Claim Objections

Claim 1 is objected to because of the following informalities: it is suggested to change "homogenising" to "homogenizing". Appropriate correction is required.

Page 3

Application/Control Number: 09/601,958

Art Unit: 1763

Claim 27 is objected to because of the following informalities: it is suggested to change the dependency of the claim from 25 to 26 since claim 25 has been cancelled. Appropriate correction is required.

Claim Rejections - 35 USC § 112

Claims 1, 2, 4, 6-9, 12-15, 21 and 26-28 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

In claims 1, line 6 and in claim 26, line 5, the word "radical" generally means an atomic or molecular species having at least one unpaired electron and the radical species may be neutral, positively charged or negatively charged. it is suggested to insert "neutral" before "radical".

In claim 21, line 3, "field" is vague as it may mean electrical or magnetic; it is suggested to insert "magnetic" before "field".

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1, 2, 4, 6, 26 are rejected under 35 U.S.C. 102(b) as being anticipated by Amemiya et al (EP 0488393 A2).

Amemiya et al teach a plasma processing apparatus (Fig. 2) comprising:

a chamber 14 having a section 24 at which a wafer 2 is supported on a wafer mount 23 and an upper section 25 at which a plasma is generated from a gas introduced via an inlet gas 31

Art Unit: 1763

by high frequency electrodes 28a, 28b (means for striking a plasma in a chamber having a gas inlet and a support for a substrate); and

an ion trap 38 for trapping ions in the plasma to send neutral radicals into the wafer treating section 24 (attenuation means for reducing and/or homogenizing the ion flux from the plasma substantially without affecting the neutral radical number density) (abstract and column 4, line 47 through column 5, line 35).

Regarding claim 2: means for providing alternating etch and deposition step is interpreted as etching and deposition gas sources which are considered process limitations rather than structural limitation and the etching apparatus of Amemiya et al (column 5, lines 8-16) is inherently capable of being used for a deposition process.

Regarding claim 4: the upper section 26 is made of quartz (dielectric material) (column 5, line 1).

Regarding claim 6: the electrodes 28a, 28b are wound around the quartz tube 26 of the upper section 25 (column 5, lines 4-7).

Claims 1, 2, 4, 6-9, 12, 21, 26-28 are rejected under 35 U.S.C. 102(b) as being anticipated by Ohkawa et al (EP 0831516 A2).

Ohkawa et al teach a plasma processing apparatus (Fig. 1) comprising:

a vessel 12 defining a chamber 28 having a substrate 26 supported on a pedestal 24 and having a plasma 48 generated therein from a gas introduced therein via an inlet gas (not shown) through propagating radio-frequency power into the chamber via an antenna 22 (means for striking a plasma in a chamber having a gas inlet and a support for a substrate); and

Art Unit: 1763

a magnet 30 generating magnetic field parallel to the surface of the substrate for trapping ions in the plasma to send neutral radicals into the substrate (attenuation means for reducing and/or homogenizing the ion flux from the plasma substantially without affecting the neutral radical number density) (abstract and column 6, line 19 through column 8, line 2).

Regarding claim 2: means for providing alternating etch and deposition step is interpreted as etching and deposition gas sources which are considered process limitations rather than structural limitation. Further the apparatus of Ohkawa et al can be used for etching as well as for deposition (column 6, line 54).

Regarding claim 4: the vessel 12 is made of an insulating material (dielectric material) such as glass (column 6, lines 19-31).

Regarding claim 6: the antenna 22 is disposed above the vessel 12 (column 6, lines 32-44).

Regarding claim 7-9, 12, 21, 27, 28: the magnetic field may be produced by a permanent magnet or an electro-magnetic device (column 7, lines 2-16).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any

Art Unit: 1763

evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claim 13 is rejected under 35 U.S.C. 103(a) as being unpatentable over Ohkawa et al (EP 0831516 A2) in view of Kin (JP61-39521 A).

Ohkawa et al teach all limitations of the claims as discussed above except for the attenuation means (magnetic generating filed) comprising a tubular member carrying magnets.

Kin teaches a plasma processing apparatus including a pole-like electrode 101 having a plurality of magnets 103, 104, ... embedded therein wherein the electrode is inserted inside a plasma chamber 110 (abstract).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to implement the magnetic arrangement as taught by Kin in the apparatus of Ohkawa et al in order to protect the magnets from plasma when the magnetic field generating device is disposed inside the plasma chamber.

Claims 14, 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ohkawa et al (EP 0831516 A2) in view of Ribeiro (US Patent No. 4,769,101).

Ohkawa et al teach all limitations of the claims as discussed above except for the attenuation means (magnetic generating filed) comprising a tubular member carrying magnets.

Ribeiro teaches a plasma processing apparatus (Fig. 1) including a magnet coil 51 cooled by a cooling system 52 having a cooling-fluid line 53 (column 6, lines 22-33).

Art Unit: 1763

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to implement cooling mechanism as taught by Ribeiro in the apparatus of Ohkawa et al in order to control the temperature of the magnets particularly if it is desired to dispose the magnets inside the chamber.

Claims 14, 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ohkawa et al (EP 0831516 A2) in view of Maeno et al (US Patent No. 6,060,836).

Ohkawa et al teach all limitations of the claims as discussed above except for the attenuation means (magnetic generating filed) comprising a tubular member carrying magnets.

Maeno et al teach a plasma processing apparatus (Fig. 1) including permanent magnets 40 cooled by a water-cooled structure comprising a cooling water passage (not shown) within the central conductor 22 in order to remove heat generated by plasma and thus to protect the magnets (column 5, lines 60-65).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to implement cooling mechanism as taught by Maeno et al in the apparatus of Ohkawa et al in order to remove heat from the magnets particularly if it is desired to dispose the magnets inside the chamber.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Lagarde et al (US Patent No. 6,403,490 B1) teach a plasma reactor including a series of magnets disposed between two parallel electrodes for oscillating electrons between magnetic poles;

Application/Control Number: 09/601,958 Page 8 Art Unit: 1763 Watanabe (JP 2-118055 A) teach a plasma reactor including a magnet 11 cooled by a cooling mechanism as shown in Fig. 1. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Parviz Hassanzadeh whose telephone number is (703)308-2050. The examiner can normally be reached on Tuesday-Friday. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory L. Mills can be reached on (703)308-1633. The fax phone numbers for the organization where this application or proceeding is assigned are (703)872-9310 for regular communications and (703)872-9311 for After Final communications. Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0661. P. HavenJadt Parviz Hassanzadeh Examiner Art Unit 1763 October 16, 2002